



RESPONSE UNDER 37 C.F.R. 1.116 **EXPEDITED PROCEDURE--EXAMINING GROUP 2134**

Confirmation No.: 3570

Group Art Unit: 1762

forney's Docket No. 5308-157IP2

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re: Das et al.

Serial No.: 10/045,542

Filed: October 26, 2001

For:

Examiner: Kirsten Jolley METHOD OF FABRICATING AN OXIDE LAYER ON A SILICON CARBIDE

LAYER UTILIZING AN ANNEAL IN A HYDROGEN ENVIRONMENT

Date: July 18, 2005

Mail Stop AF Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

REQUEST FOR RECONSIDERATION

Sir:

Applicants provide the present Request for Reconsideration to address the issues raised in the Final Official Action mailed May 18, 2005.

It is not believed that an extension of time and/or additional fee(s)-including fees for net addition of claims-are required, beyond those that may otherwise be provided for in documents accompanying this paper. In the event, however, that an extension of time is necessary to allow consideration of this paper, such an extension is hereby petitioned under 37 C.F.R. §1.136(a). Any additional fees believed to be due in connection with this paper may be charged to our Deposit Account No. 50-0220.

While no amendments to the claims have been made, a Listing of Claims is provided for the Examiner's convenience and begins on page 2 of this paper.

Remarks begin on page 5 of this paper.